

# Designing Piezoelectric Micro- actuators Using COMSOL

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# Agenda

- Introduction
- Piezoelectric MEMS Design
- Numerical Models
- Experimentation
- Results
- Conclusion



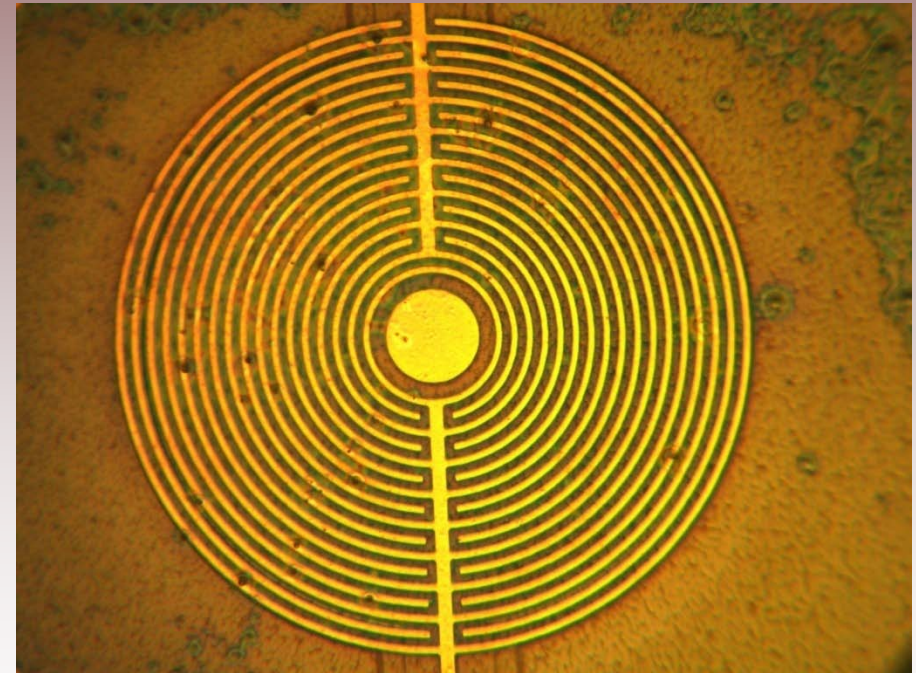
# Introduction

## Planar Sandwich

$d_{31}$  actuation

## Interdigitated

$d_{33}$  actuation



$d_{33}$  – piezoelectric coupling ( $\sim 3|d_{31}|$ )



# Piezoelectric MEMS Design Parameters

- Piezoelectric Thickness
- Center Disk Diameter
  - Design Parameter Coupling
- Physical Boundary Conditions
- Electrode Width
- Electrode Separation (Pitch)
- Number of Electrodes
  - Separate or Design Parameter Coupling
- Voltage Polarity



# Numerical Modeling Interdigitated Actuator Pre-Processing

Material	Thickness (μm)	Young's Modulus (GPa)	Poisson's Ratio	Density (kg/m <sup>3</sup> )
Gold	0.5	80	0.42	19280
ZrO <sub>2</sub>	0.4	86	0.27	4600
SiO <sub>2</sub>	0.7	74.5	0.17	2200
Al <sub>2</sub> O <sub>3</sub>	0.25	376.91	0.24	3895

- Geometry
  - Diameter = 700 μm
- Assumptions
  - 2D axi-symmetric model with symmetric boundary conditions

- ▣ PZT-5H
  - Stiffness Matrix
  - Piezoelectric Coupling Constants
  - Permittivity Constants

$$c = \begin{bmatrix} 126 & 79,5 & 84,1 & 0 & 0 & 0 \\ & 126 & 84,1 & 0 & 0 & 0 \\ & & 117 & 0 & 0 & 0 \\ & & & 23,3 & 0 & 0 \\ sym & & & & 23,0 & 0 \\ & & & & & 23,0 \end{bmatrix} GPa$$

$$e = \begin{bmatrix} 0 & 0 & 0 & 0 & 0 & 17 \\ 0 & 0 & 0 & 0 & 17 & 0 \\ -6,5 & -6,5 & 23,3 & 0 & 0 & 0 \end{bmatrix} \frac{C}{m^2}$$

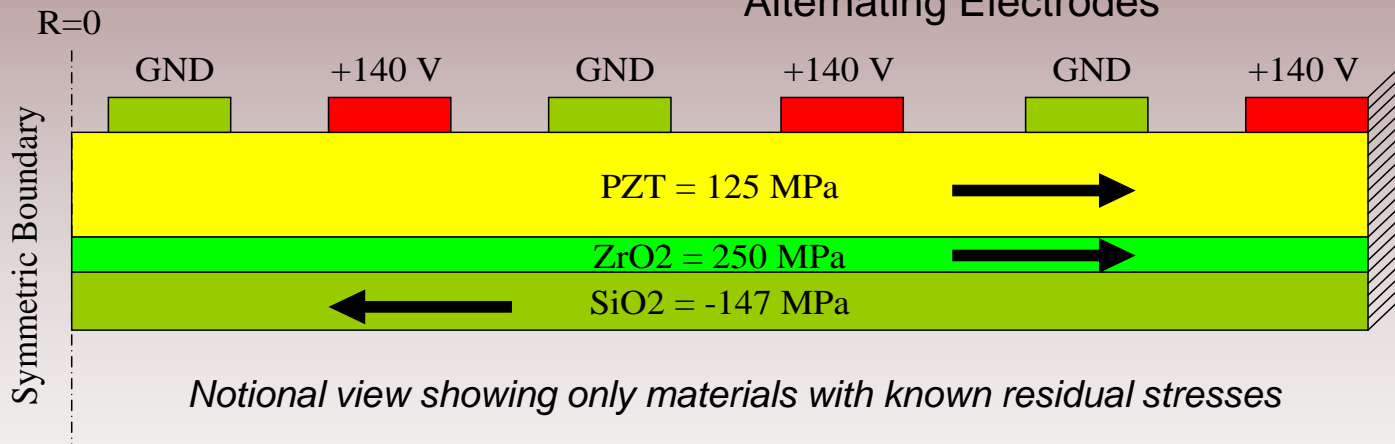
$$\epsilon = \begin{bmatrix} 1,503 & 0 & 0 \\ 0 & 1,503 & 0 \\ 0 & 0 & 1,3 \end{bmatrix} \times 10^{-8} \frac{F}{m}$$



# Numerical Modeling

## Interdigitated Actuator Pre-Processing

- Symmetric Constraint Boundaries on center radius
- Clamped BC on External Radius
- $d_{33}$  – piezoelectric coupling ( $\sim 3|d_{31}|$ )
- Design Considerations
  - Positive electrode on clamped circumference
  - Applied Voltage = 140 VDC (500mA) on Alternating Electrodes



### Spin Coated & Annealed Processing for PZT and $ZrO_2$

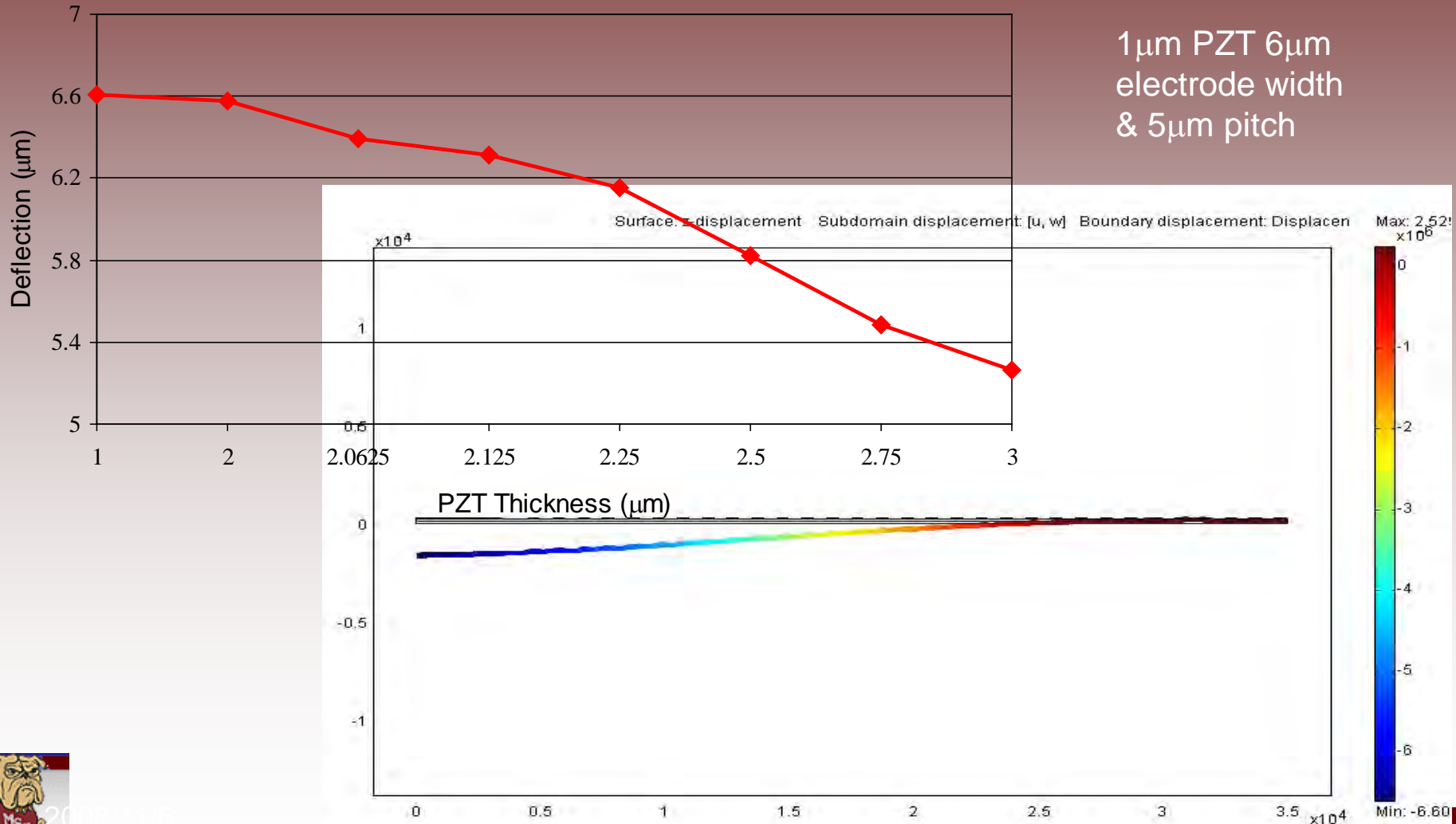
- Low temperature deposition of  $SiO_2$
- Processing stack-up tolerance  $\sim 0.6 - 0.9\mu m$



# Design Parameters

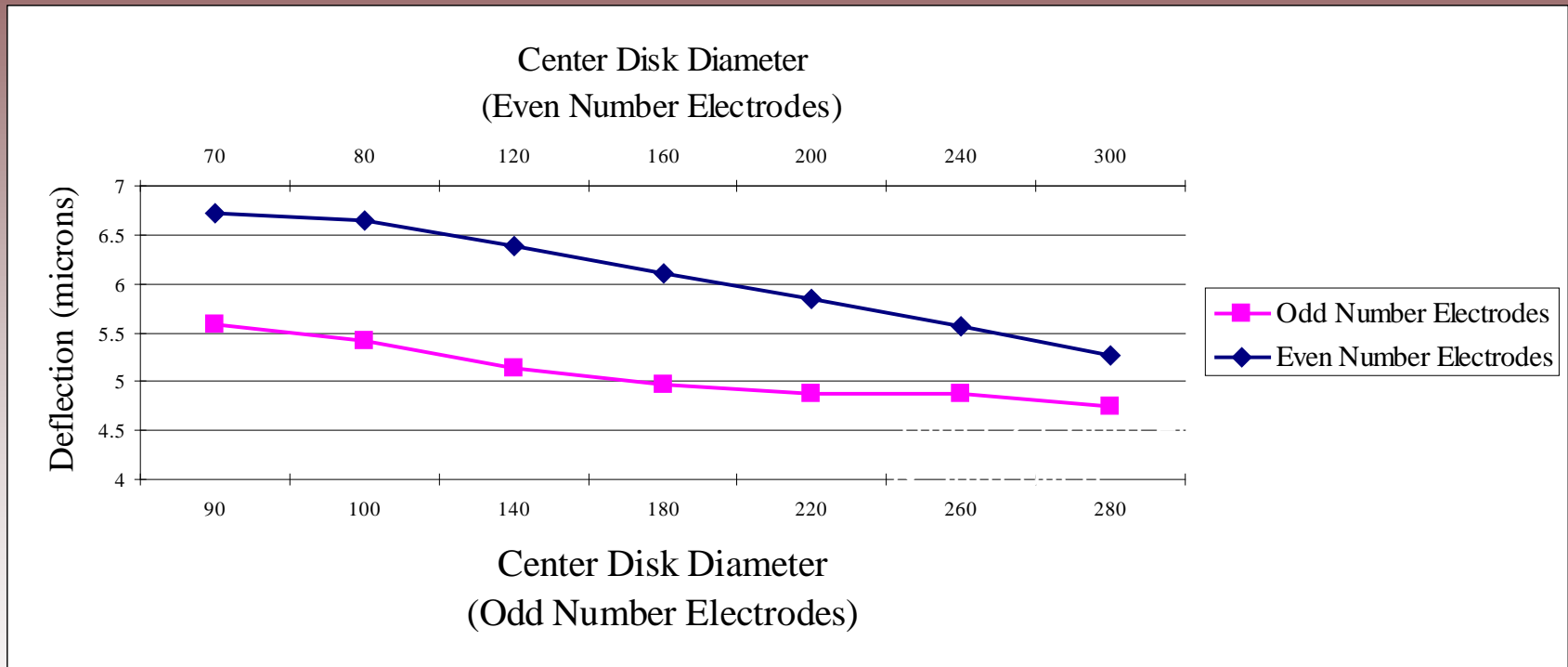
## Deflection vs. PZT Thickness

1  $\mu\text{m}$  PZT 6  $\mu\text{m}$  electrode width & 5  $\mu\text{m}$  pitch



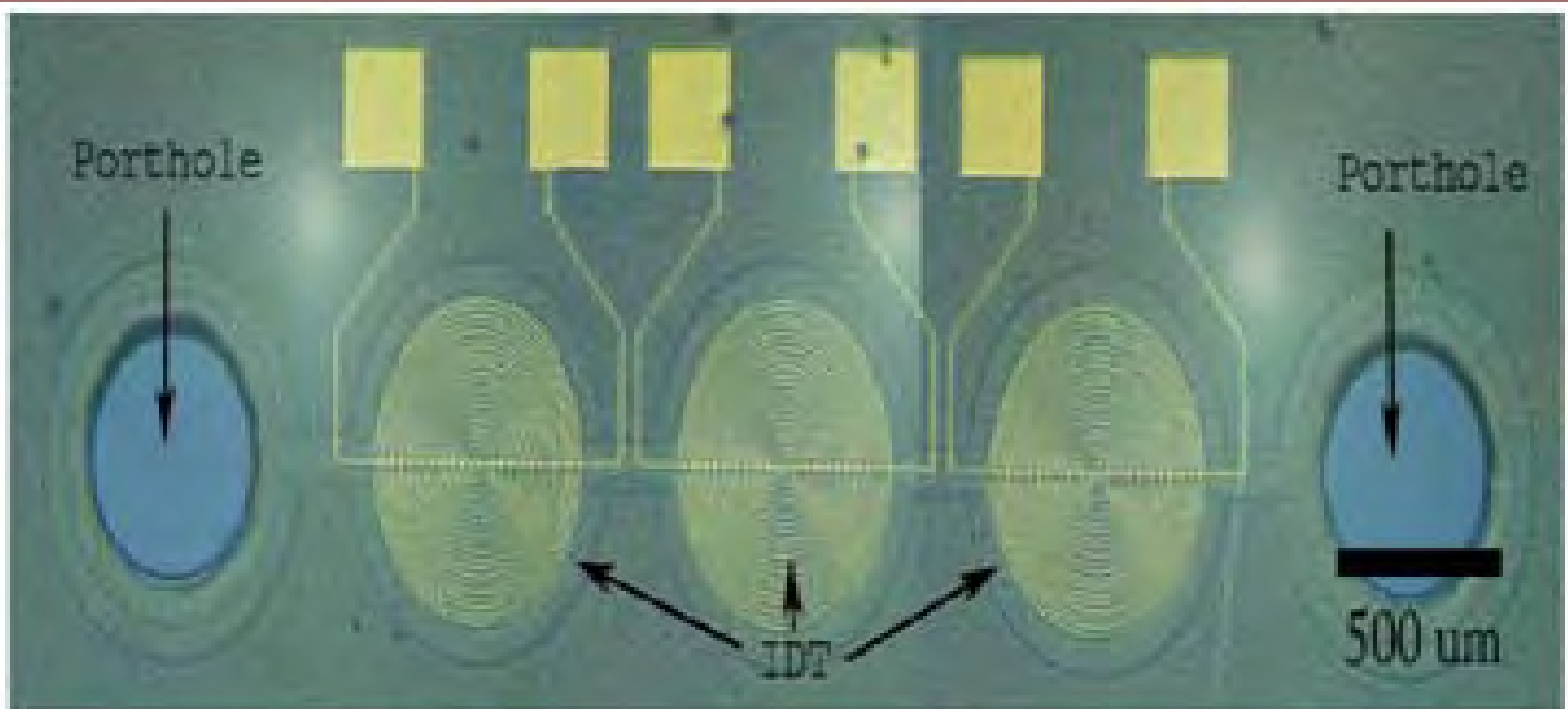
# Design Parameters

## Deflection vs. Center Disk Diameter



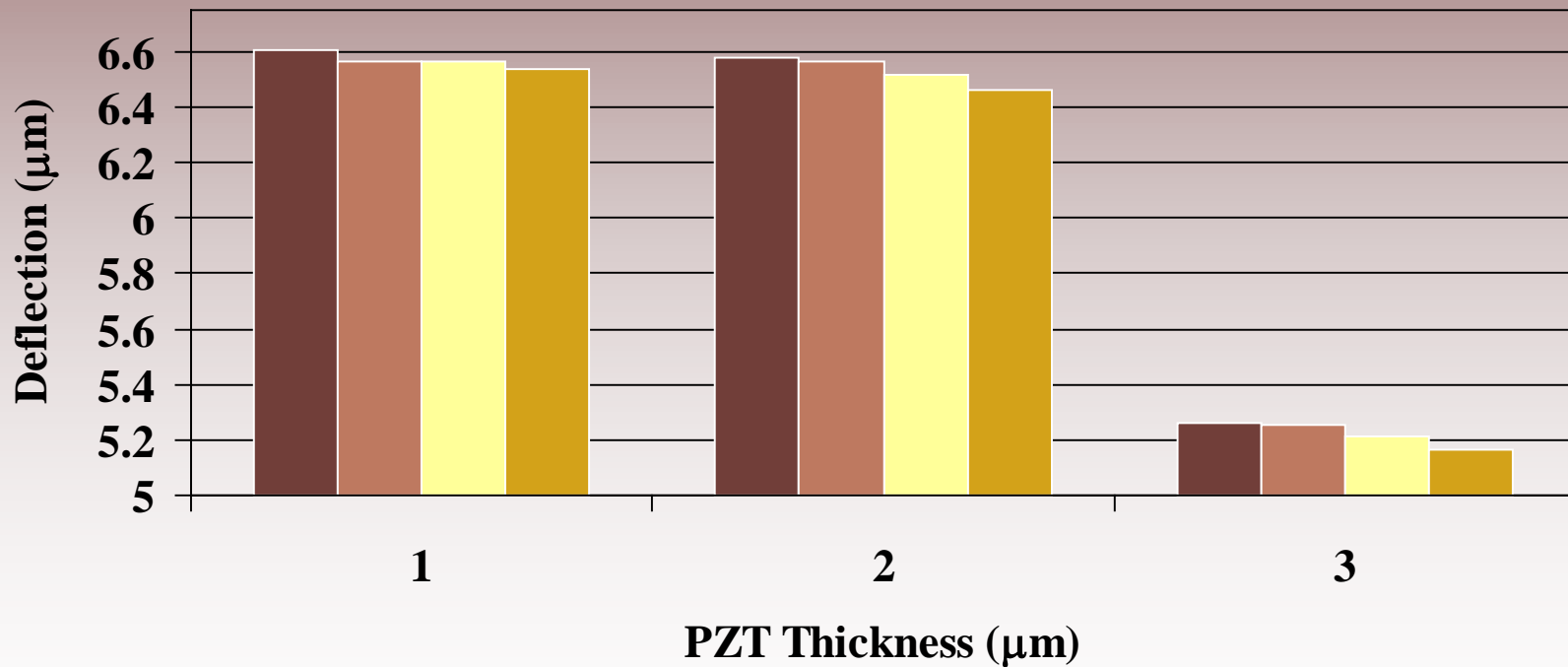
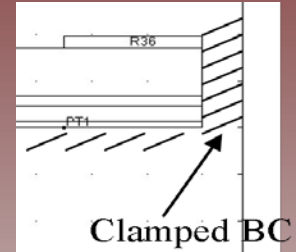
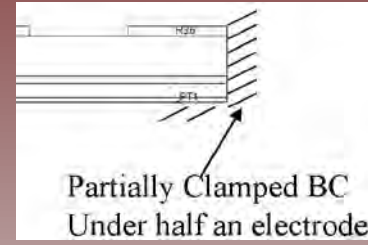
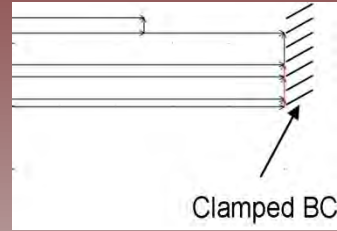
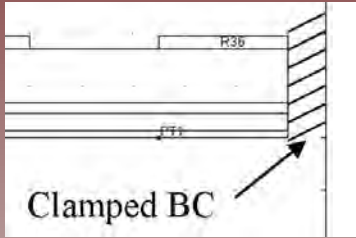


# Piezoelectric MEMS Design - Electrode Boundary Position



# Design Parameters

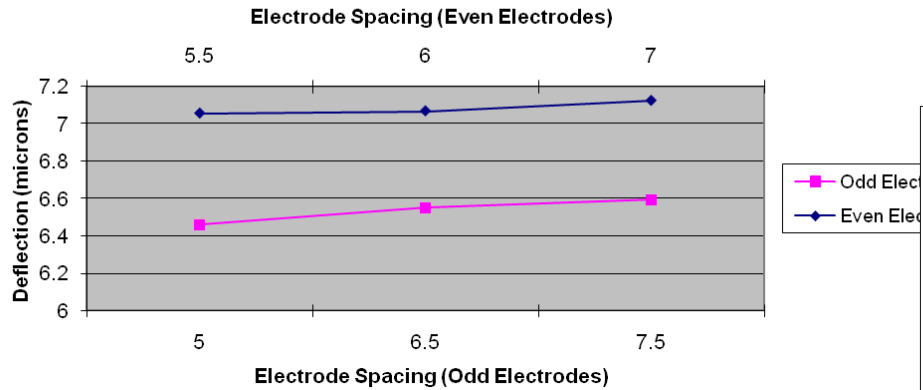
## Deflection vs. Electrode Position/Boundary Conditions



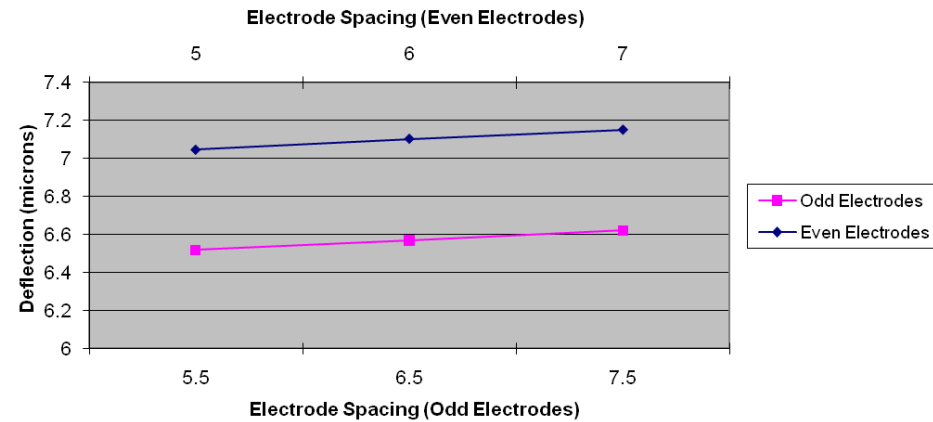
- Flush Electrodes
- Offset Electrodes
- Partially Clamped Electrodes
- Clamped Electrodes



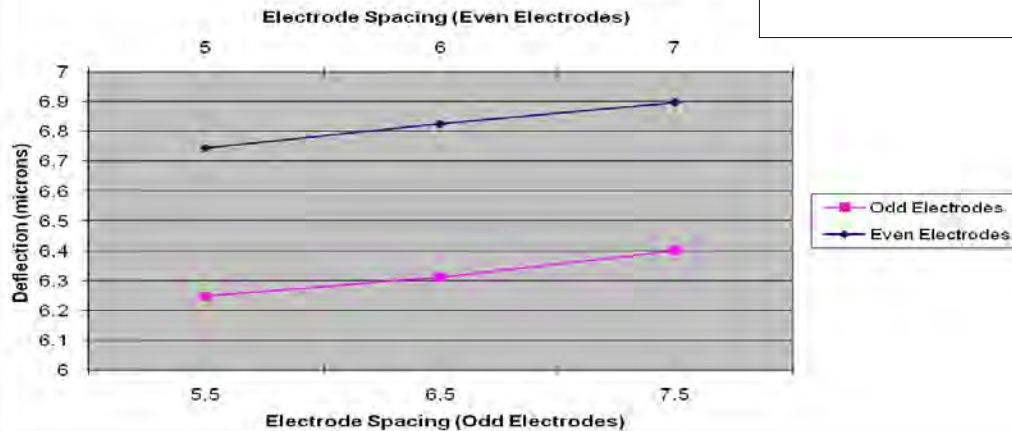
Deflection vs. Electrode Spacing  
2 Micron PZT 5 Micron Electrode Width



Deflection vs. Electrode Spacing  
2 Micron PZT 6 Micron Electrode Width

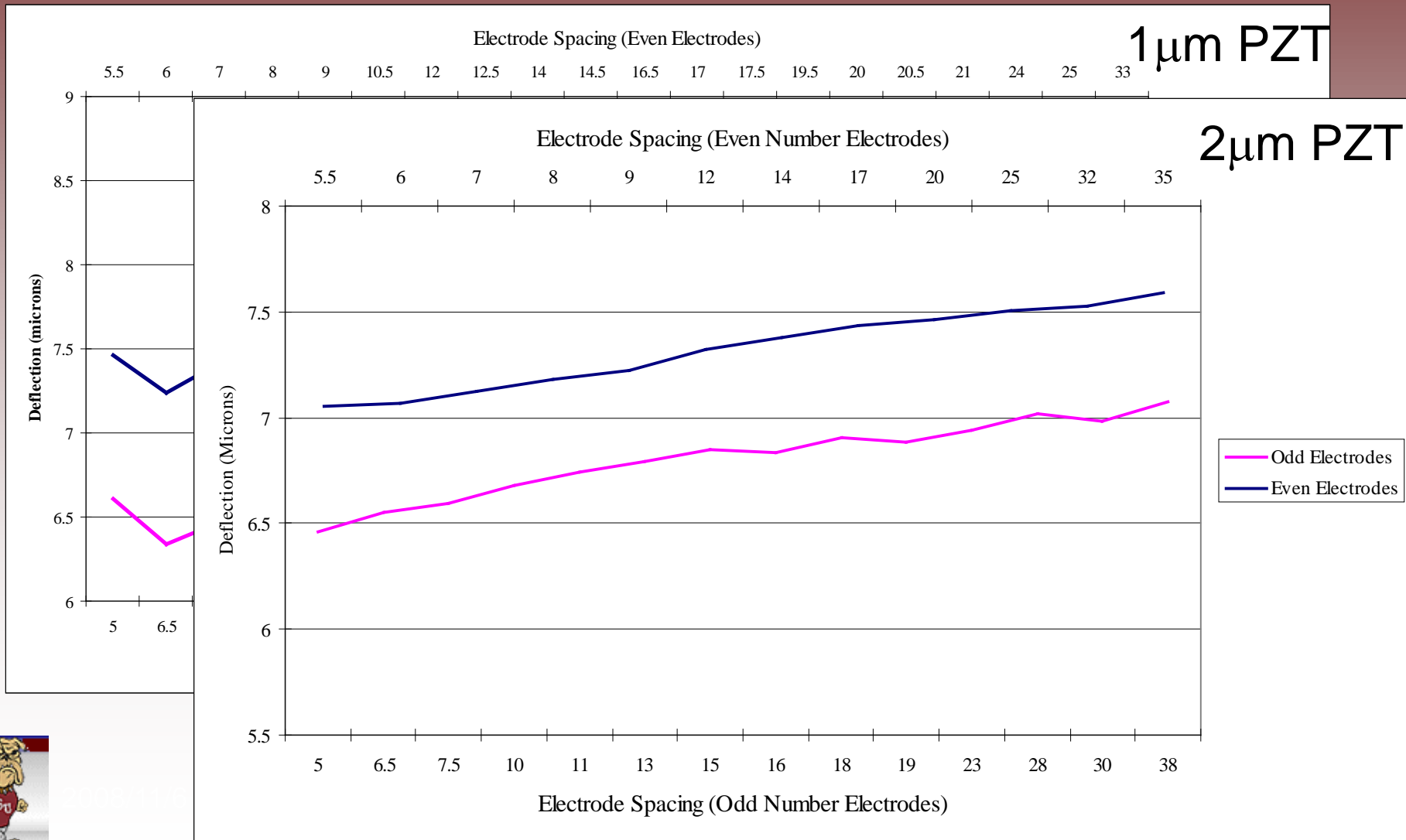


Deflection vs. Electrode Spacing  
2 Micron PZT 7 Micron Electrode Width



# Design Parameters

## Electrode Separation Simulation

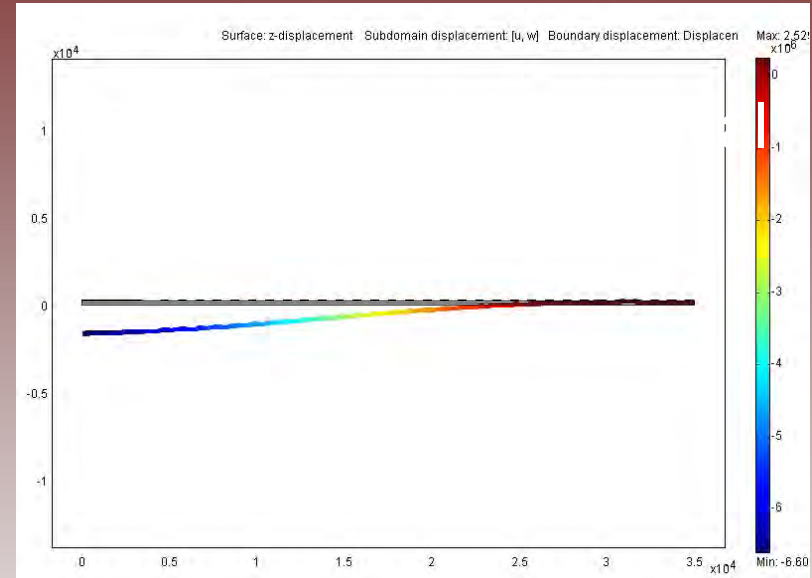
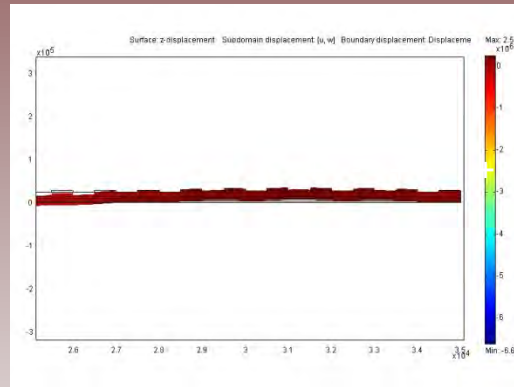


# Design Parameters

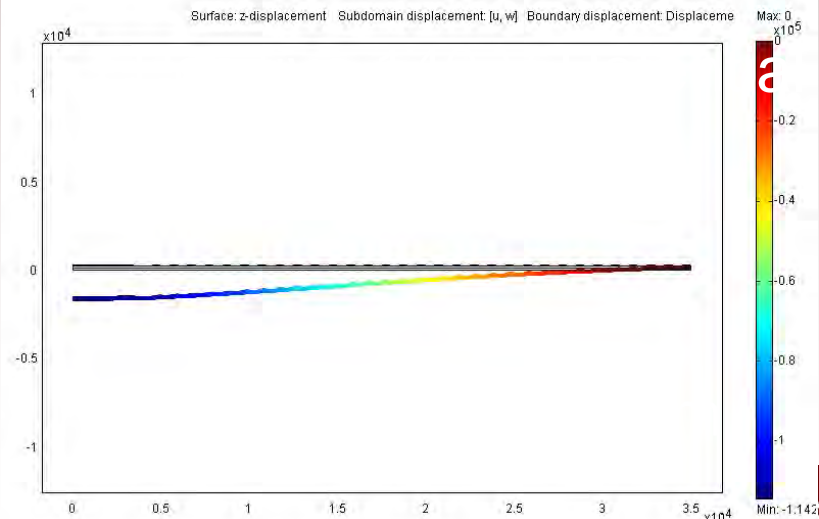
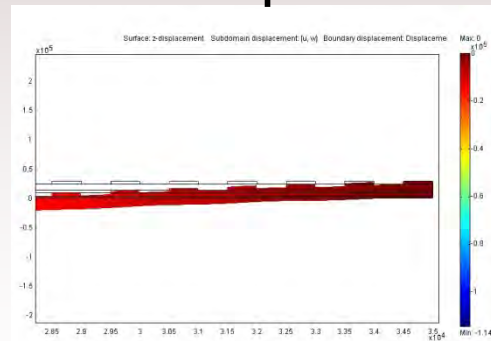
## Electrode Polarization (1 $\mu\text{m}$ PZT)

### Positive Electrodes on Clamped End

- Flush Electrodes
- 70  $\mu\text{m}$  Center Disk
- 5  $\mu\text{m}$  Electrode Width
- 5  $\mu\text{m}$  Electrode Spacing
- 1  $\mu\text{m}$  PZT

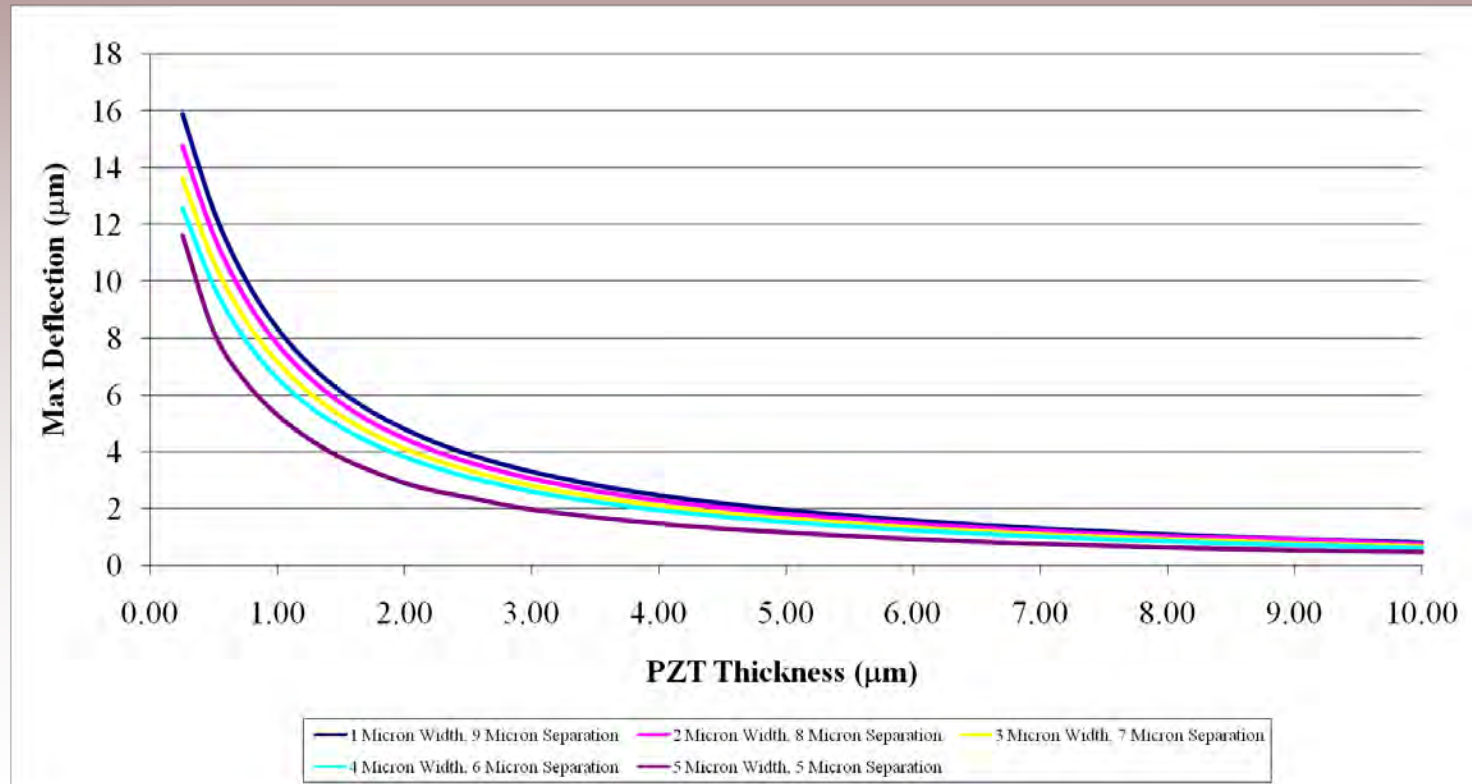


### Ground Electrodes on Clamped End



# Piezoelectric MEMS Design Parametric Analysis

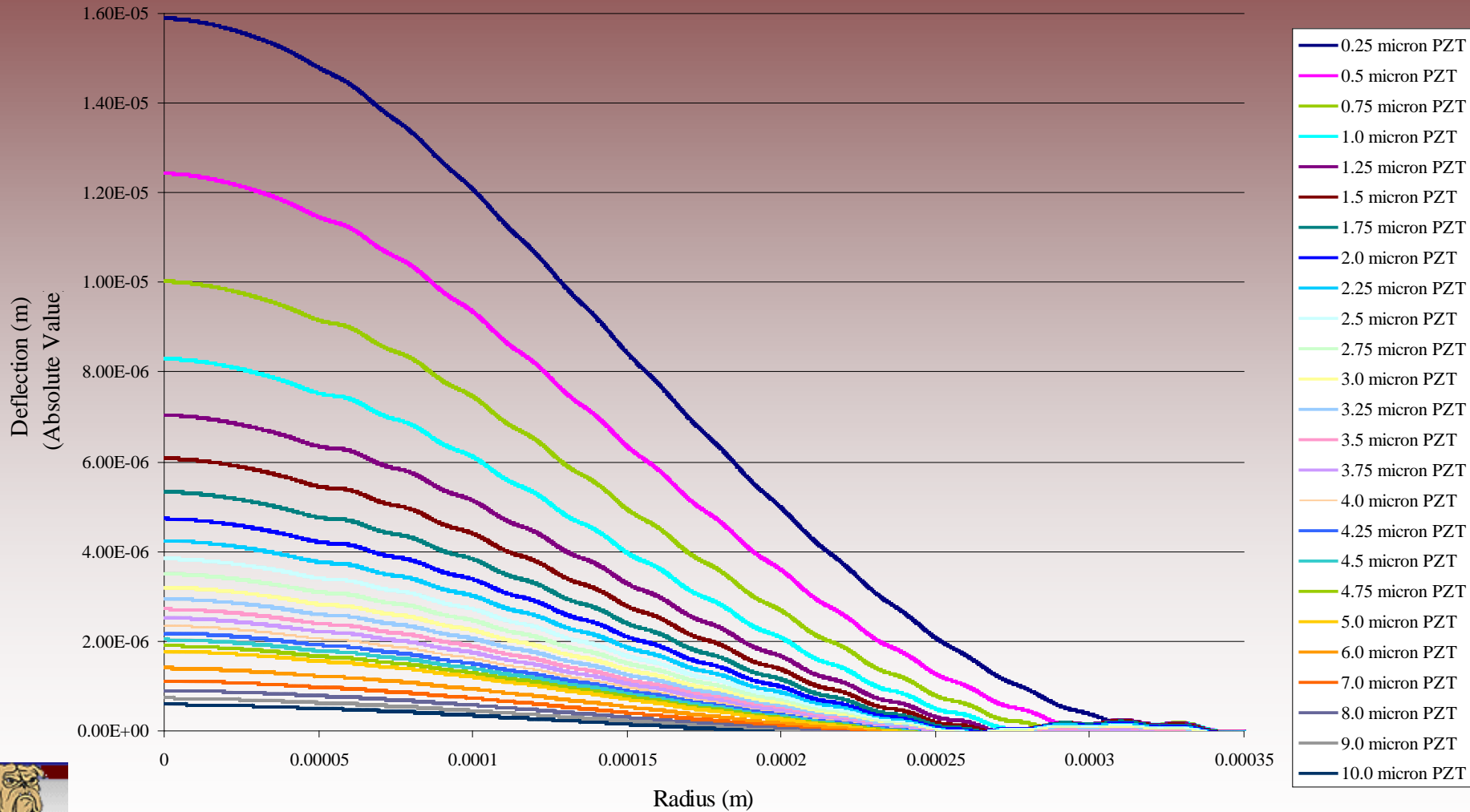
- Models normalized based on diaphragm diameter
  - Material thicknesses with an emphasis on piezoelectric thickness
  - Electrode width
  - Electrode separation
  - Center disk diameter



# Design Optimization

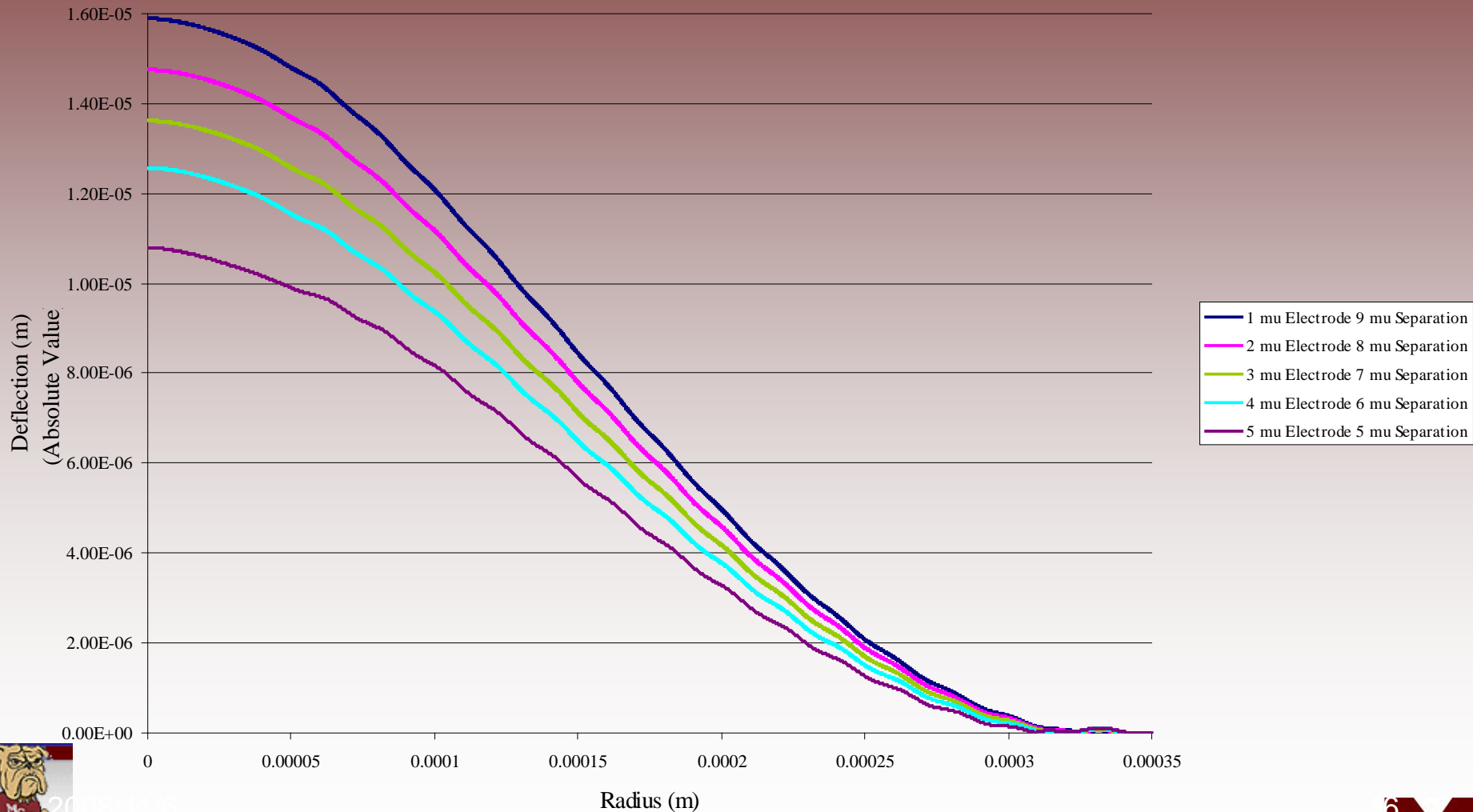
## Parametric Models - Deflection vs. PZT Thickness

(1  $\mu\text{m}$  electrode width, 9  $\mu\text{m}$  electrode pitch)



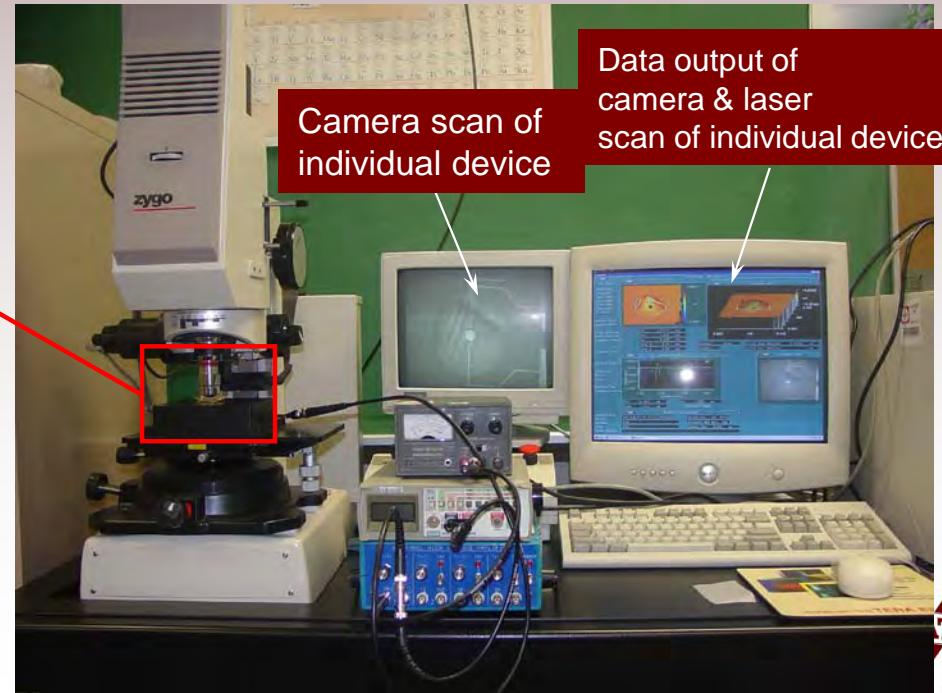
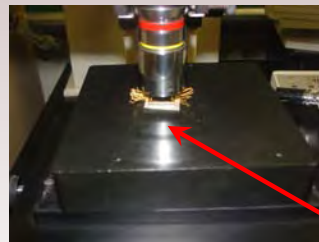
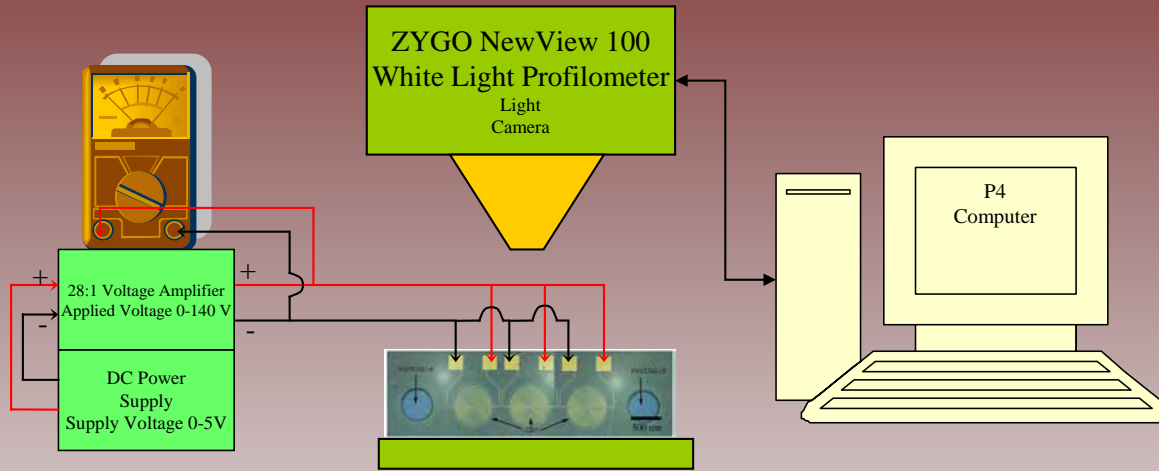


## Parametric Models - Deflection vs. PZT Thickness (0.25 $\mu\text{m}$ PZT, varying electrode width and pitch)





# Experimentation – Static Deflection



**Zygo** Microscope Application

10X Mirau

MEASURE  
Analyze  
Mask Data  
Save Data  
Load Data  
Calibrate  
Reset

Measure Cntrl  
Analyze Cntrl

Stage Controls  
Focus Controls  
Sequence Control

Test+Ref Ctrl

Surface Profile

Slope Mag  
Slope X  
Slope Y

Spectrum Map  
Spectrum Profil

Analyze Attr  
Report  
Process  
Units  
Video Monitor

**Zygo** Surface Map

**Zygo** Oblique Plot

PV 3.946 um  
rms 0.665 um  
Ra 0.438 um  
Size X 0.34 mm  
Size Y 0.26 mm

Removed: Plane  
Trimmed: 0  
Filter High Wavelen: 0.00319 mm  
Filter Low Wavelen: mm

**Zygo** Surface Profile

PV 3.828 um  
rms 1.272 um  
Ra 1.116 um

Profile Stats

**Zygo** Intensity Map

**Zygo** Measure Attributes

Fri Jul 28 11:35:49 2006  
Objective: 10X Mirau  
E/N:  
Subtract Sys Err: Off  
S/N:  
Camera Res: 1.064 um



# Deflection vs. Polarity of Experimental Diaphragms

Diaphragm	Deflection ( $\mu\text{m}$ )	
	Positive Inside	Positive Outside
Actuator 1 Lot 4-4-1	Broken	
Actuator 2 Lot 4-4-1	3.49	2.52
Actuator 1 Lot 4-4-2	3.20	2.55
Actuator 2 Lot 4-4-2	3.40	3.49
Actuator 4 Lot 4-4-2	2.85	2.79
Actuator 4 Lot 4-4-3	2.93	2.90



# 650 mm Diaphragm w/ 90 mm Center Disk

Note: Odd Number of Electrodes (21)

Residual Stresses (MPa)					
Voltage	ZrO <sub>2</sub>	SiO <sub>2</sub>	PZT	$\delta_{exp}$ ( $\mu m$ )	$\delta_{sim}$ ( $\mu m$ )
100	270	206	60	3.93	3.933
140	350	245	0	6.44	6.452
180	400	305	0	7.93	7.99

$\delta_{max\_exp180V} = 7.98 \mu m$



# 650 mm Diaphragm w/ 150 mm Center Disk



Note: Even Number of Electrodes (18)

Residual Stresses (MPa)					
Voltage	ZrO <sub>2</sub>	SiO <sub>2</sub>	PZT	$\delta_{exp}$ ( $\mu m$ )	$\delta_{sim}$ ( $\mu m$ )
100	270	205	130	2.13	2.136
140	360	255	0	5.86	5.88
180	410	315	0	7.17	7.13

$\delta_{max\_exp180V} = 7.17 \mu m$



# 650 mm Diaphragm w/ 210 mm Center Disk

Large Center Disk and 15 electrodes

Residual Stresses (MPa)					
Voltage	ZrO <sub>2</sub>	SiO <sub>2</sub>	PZT	$\delta_{exp} (\mu m)$	$\delta_{sim} (\mu m)$
100	29	29	0	1.44	1.435
140	30	35	30	1.45	1.424
180	0	0	30	1.41	1.415

$$\delta_{max\_exp140V} = 1.45 \mu m$$



# Conclusion

- Identify trends for critical design parameters
  - Piezoelectric thickness, electrode pitch & width, center disk diameter, voltage polarity, physical boundary conditions, number of electrodes
- Design optimization beginnings
- Showed the effects of design parameter(s) coupling/combinations on deflection
- Experiments verified the decreasing deflection trend with respect to center disk diameter
- Initial verification of the effect of even number of electrodes on deflection (closed circuit)
- Identified the difference in deflection with respect to polarity
- Combined numerical models with given experimental data for design optimization beginnings

